BACHELOR OF PRINTING ENGINEERING EXAMINATION, 2009

(2nd Year-2nd Semester) PRINTING SURFACE PREPARATION

Time: Three hours Full Marks: 100

Answer Question No.1 from Group-A and any Two Questions from Group-B and any
Two Questions from Group-C

Group-A

- 1. (a) What are the merits and demerits of the Brush Graining Process?
 - (b) What is the base metal for offset plate?
 - (c) What is the material used for forming the image areas of deep etch plate?
 - (d) What is the material used for forming the image areas of egg-albumen plate?
- (e) What are the material used for forming the image and non-image areas of the waterless offset plate?
- (f) Why water is sprayed over the counter-etched plates just before application of coating?
- (g) What are the constituents of the coating solution used for egg-albumen plate making?
- (h) What are the constituents of the coating solution used for gum deep etch plate making?
- (i) What are the constituents of the regular developing solution used for the development of gum deep etch plate?
 - (j) What is the purpose of the Sodium Silicate layer in the Presensitized plate?

4+1+1+1+2+3+2+2+2+2=20

Group-B

- 2. (a) What are the purposes of graining the plate used in Lithographic Printing Surface Preparation?
- (b) What are the factors which influence the mechanical graining of the lithographic plates?
 - (c) What are the purposes of anodizing the lithographic plates? 5+10+5=20

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- 3. (a) Why the pH of the gum arabic solution used in desensitizing of lithographic plate should be kept near about 3.0 for most effective result?
 - (b) What are the purposes of counter etching the base metal for lithoplate?
- (c) What are the properties the gum arabic solution possess for which it is considered as a desensitizing solution for lithographic plate making?
- (d) Discuss the effect of relative humidity and surface treatment on the coating thickness of bichromated egg-albumen and gum-deep-etch coatings used in lithography.

5+5+5+5=20

4. What are the factors which influence the sensitivity to light of the bichromated colloidal films used in lithographic plate making? Discuss in brief.

Group-C

5. (a) What are the merits and demerits of waterless offset process?

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- (b) What are the properties the Silicone Resin have for which it is used as imaging material for the non-image portions of the waterless offset plate?
- (c_c) What do you mean by additive and subtractive pre-sensitized plate? Discuss in brief.
 - (d) What are the preferences of the platemaker and printer so far as plate grain is concerned? Discuss with reason.
 - (e) Discuss how the porosity of the grain surface can be increased. 5+4+4+4+3=20
 - 6. (a) Discuss with neat sketch the basic configuration of Negative working waterless offset plate.
 - (b) Discuss in brief, the Imaging and Developing of the Negative Working Waterless

 Offset Plate.

 5+15=20
- 7. (a) What are the factors which affect the thickness of the bichromated colloidal coating on grained Al plate used in Lithographic Printing Surface Preparation? Discuss in brief.
 - (b) What are the advantages of the Deep etch plates over the surface plates used in Lithographic Printing Surface Preparation?
 - (c) Discuss in brief, how the plate grains are evaluated.

6+7+7=20